

NO-A101 214

GAS SOURCE MBE (MOLECULAR BEAM EPITAXY) (U) COLORADO
STATE UNIV FORT COLLINS DEPT OF ELECTRICAL ENGINEERING
G L ROBINSON MAR 87 AFOSR-TR-87-0748 AFOSR-87-0028

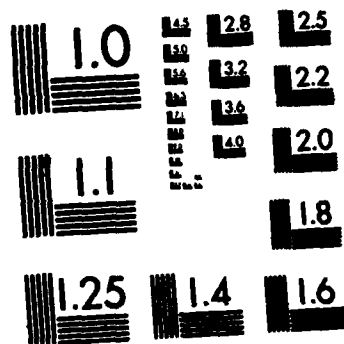
1/1

UNCLASSIFIED

F/G 20/2

NL





MICROCOPY RESOLUTION TEST CHART
NATIONAL BUREAU OF STANDARDS-1963-A

REPORT DOCUMENTATION PAGE

1a. REPORT SECURITY CLASSIFICATION UNCLASSIFIED		1b. RESTRICTIVE MARKINGS	
2a. SECURITY CLASSIFICATION AUTHORITY		3. DISTRIBUTION/AVAILABILITY OF REPORT Approved for Public Release Distribution Unlimited	
4. AD-A181 214		5. MONITORING ORGANIZATION REPORT NUMBER(S) AFOSR-TR- 87- 0748	
6a. NAME OF PERFORMING ORGANIZATION Colorado State University	6b. OFFICE SYMBOL (If applicable)	7a. NAME OF MONITORING ORGANIZATION AFOSR	
6c. ADDRESS (City, State and ZIP Code) Fort Collins, Co 80523		7b. ADDRESS (City, State and ZIP Code) Bldg 410 Bolling AFB, DC 20332-6448	
8a. NAME OF FUNDING/SPONSORING ORGANIZATION AFOSR	8b. OFFICE SYMBOL (If applicable) NE	9. PROCUREMENT INSTRUMENT IDENTIFICATION NUMBER AFOSR-87-0028	
8c. ADDRESS (City, State and ZIP Code) Bldg 410 Bolling AFB, DC 20332-6448		10. SOURCE OF FUNDING NOS.	
		PROGRAM ELEMENT NO. 61102F	PROJECT NO. 2917
		TASK NO. A3	WORK UNIT NO.
11. TITLE (Include Security Classification) GAS SOURCE MBE			
12. PERSONAL AUTHOR(S) Professor Gary Robinson			
13a. TYPE OF REPORT Interim Report	13b. TIME COVERED FROM 01/10/86 to 30/09/87	14. DATE OF REPORT (Yr., Mo., Day)	15. PAGE COUNT 3
16. SUPPLEMENTARY NOTATION			
17. COSATI CODES		18. SUBJECT TERMS (Continue on reverse if necessary and identify by block number)	
FIELD	GROUP	SUB. GR.	
19. ABSTRACT (Continue on reverse if necessary and identify by block number) The objective of the research supported by the grant to grow expitaxial III-V semiconductor films using gaseous source materials for molecular beam epitaxy(MBE). The grant provides the critical equipment items needed to customize an existing commercial MBE system and allow growth of heteroepitaxial structures that can not be fabricated by other existing techniques.			
20. DISTRIBUTION/AVAILABILITY OF ABSTRACT UNCLASSIFIED/UNLIMITED <input checked="" type="checkbox"/> SAME AS RPT. <input type="checkbox"/> DTIC USERS <input type="checkbox"/>		21. ABSTRACT SECURITY CLASSIFICATION UNCLASSIFIED	
22a. NAME OF RESPONSIBLE INDIVIDUAL Capt. Malloy		22b. TELEPHONE NUMBER (Include Area Code) (202) 767-4931	22c. OFFICE SYMBOL NE

DTIC
ELECTE
JUN 11 1987
S D

AFOSR-TB- 87 - 0748

**Interim Status Report
to the
Air Force Office of Scientific Research
for**

URIP Grant No. AFOSR-87-0028

(1 Oct. 1986 to 30 Sept. 1987)

entitled

"Gas Source MBE"

at

Colorado State University

Fort Collins, CO 80523

**Approved for public release;
distribution unlimited.**

PI: Gary Y. Robinson

Department of Electrical Engineering

(303) 491-6575

March 1987

**AIR FORCE OFFICE OF SCIENTIFIC RESEARCH (AFSC)
NOTICE OF TRANSMITTAL TO DTIC
This technical report has been reviewed and is
approved for public release IAW AFR 190-12.
Distribution is unlimited.
MATTHEW J. KERPER
Chief, Technical Information Division**

Accession For	
NTIS CRA&I	<input checked="checked" type="checkbox"/>
DTIC TAB	<input type="checkbox"/>
Unannounced	<input type="checkbox"/>
Justification	
By	
Distribution /	
Availability Codes	
Dist	Avail and/or Special
A-1	



87 6 10 128

Interim Status Report
AFOSR Grant # AFOSR-87-0028

This report describes the progress made during the first six months of the DoD University Research Instrumentation Program grant for "Gas Source MBE" at Colorado State University. The grant began on October 1, 1986, is of 12-months duration, and is in the amount of \$194,000.00.

The objective of the research supported by the grant to grow epitaxial III-V semiconductor films using gaseous source materials for molecular beam epitaxy (MBE). The grant provides the critical equipment items needed to customize an existing commercial MBE system and allow growth of heteroepitaxial structures that can not be fabricated by other existing techniques.

During the first six months of the grant, the following equipment items (as numbered in the original proposal) have been ordered, received, and are currently in use:

- Item 3. Vacuum system for pumping H_2 gas load from the MBE growth chamber,
- Item 4. Residual gas analyzer, and
- Item 6. Surface profilometer.

The following equipment items are on order and are expected to arrive before the end of the grant period:

- Item 1. Gas storage cabinet and special hydride gas delivery system,
- Item 2. Toxic gas monitors and alarm system, and
- Item 5. Double crystal X-ray diffractometer with computer control system.

Before ordering items 1 and 2, a considerable design effort was undertaken to ensure that the gaseous hydrides could be introduced into the UHV MBE system in a safe, controlled fashion. Item 1 is being constructed to our specifications by a gas cabinet vendor and will require additional custom work on our part after delivery of the vendor's equipment. Item 2 consists of two toxic gas monitors: one is very sensitive, requires periodic service, and will serve as the primary sensor; and the other monitor is less sensitive, requires little service, and will serve as a backup sensor. An integrated alarm system will be used to tie the two monitors together. Item 5 took several months for bidding and selection and is due for delivery in the seventh month of the grant.

The above equipment will be put into operation in the MBE Laboratory (Eng. Bldg. room C001) and the Solid State Characterization Laboratory (Eng. Bldg. rooms C004 and C012) at Colorado State University.

The procurement process for the equipment under the DoD URIP grant is on schedule and the gas source MBE system will be operation before the end of the grant period.

END

7-87

DTIC